



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Minoru YAGI

U.S. Patent Application No. 10/804,108

Filed: March 19, 2004

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Group Art Unit: 1724

Examiner: Frank M. LAWRENCE JR.

For: METHOD FOR STORING HYDROGEN, HYDROGEN CLATHRATE COMPOUND AND PRODUCTION METHOD THEREOF

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**SUBMISSION OF INFORMATION DISCLOSURE STATEMENT**

Sir:

Submitted herewith are Information Disclosure Statement, Chinese Action, English translation of Chinese Action and two references.

It is certified that the Chinese Action and the references were cited on May 19, 2006 and each item of information contained in the information disclosure statement was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of the information disclosure statement.

Respectfully submitted,

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<b>INFORMATION DISCLOSURE CITATION IN ANTI-PATENT APPLICATION</b> (PTO-1449)				ATTY. DOCKET NO. <b>K-2162</b>		U.S. PATENT APPLICATION NO. <b>10/804,108</b>	
				APPLICANT <b>Minoru YAGI</b>			
				FILING DATE <b>03/19/2004</b>		GROUP <b>1764</b>	
<b>U.S. PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
<b>FOREIGN PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
	<b>2001-261301</b>	<b>09/26/2001</b>	<b>Japan</b>			<b>Abstract</b>	
	<b>2002-106791</b>	<b>04/10/2002</b>	<b>Japan</b>			<b>Abstract</b>	
<b>OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
EXAMINER				DATE CONSIDERED			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.